

* حول جميع الأرقام إلى وحدة cm
* حول درجات الحرارة °K

TABLE 3.2 Summary of Important Equations for pn-Junction Operation

Quantity	Relationship	Values of Constants and Parameters (for Intrinsic Si at T = 300 K)
Carrier concentration in intrinsic silicon (/cm ³)	$n_i^2 = BT^3 e^{-E_G/kT}$ [1/cm ³] تعتمد فقط على الحرارة	$B = 5.4 \times 10^{31} / (K^3 \text{cm}^6)$ $E_G = 1.12 \text{ eV}$ $k = 8.62 \times 10^{-5} \text{ eV/K}$ $n_i = 1.5 \times 10^{10} / \text{cm}^3$
Diffusion current density (A/cm ²)	$J_p = -qD_p \frac{dp}{dx}$ $J_n = qD_n \frac{dn}{dx}$	$q = 1.60 \times 10^{-19} \text{ coulomb}$ $D_p = 12 \text{ cm}^2/\text{s}$ $D_n = 34 \text{ cm}^2/\text{s}$ يجب معرفة الوحدات
Drift current density (A/cm ²)	$J_{\text{drift}} = q(p\mu_p + n\mu_n)E$	$\mu_p = 480 \text{ cm}^2/\text{V}\cdot\text{s}$ $\mu_n = 1350 \text{ cm}^2/\text{V}\cdot\text{s}$
Resistivity ($\Omega \cdot \text{cm}$)	$\rho = 1/[q(p\mu_p + n\mu_n)]$ [Ω·cm] $R = \rho L/A$ [Ω]	μ_p and μ_n decrease with the increase in doping concentration
Relationship between mobility and diffusivity	$\frac{D_n}{\mu_n} = \frac{D_p}{\mu_p} = V_T$	$V_T = kT/q$ $\approx 25.8 \text{ mV}$
Carrier concentration in n-type silicon (/cm ³)	$n_{n0} \approx N_D$ $p_{n0} = n_i^2/N_D$	

Quantity	Relationship	Values of Constants and Parameters (for Intrinsic Si at T = 300 K)
Carrier concentration in p-type silicon (/cm ³)	majority: $p_{p0} \approx N_A$ minority: $n_{p0} = n_i^2/N_A$	(function of doping only!) (function of temperature)
Junction built-in voltage (V)	$V_0 = V_T \ln \left(\frac{N_A N_D}{n_i^2} \right)$	
Width of depletion region (cm)	$\frac{x_n}{x_p} = \frac{N_A}{N_D}$ $W_{\text{dep}} = x_n + x_p$ $= \sqrt{\frac{2\epsilon_s}{q} \left(\frac{1}{N_A} + \frac{1}{N_D} \right) (V_0 + V_R)}$	$\epsilon_s = 11.7\epsilon_0$ $\epsilon_0 = 8.854 \times 10^{-14} \text{ F/cm}$
Charge stored in depletion layer (coulomb)	$Q_J = q \frac{N_A N_D}{N_A + N_D} A W_{\text{dep}}$	
Depletion capacitance (F)	$C_J = \frac{\epsilon_s A}{W_{\text{dep}}}$, $C_{J0} = \frac{\epsilon_s A}{W_{\text{dep}} _{V_R=0}}$ $C_J = C_{J0} / \left(1 + \frac{V_R}{V_0} \right)^m$ $C_J \approx 2C_{J0}$ (for forward bias)	$m = \frac{1}{3} \text{ to } \frac{1}{2}$
Forward current (A)	$I = I_p + I_n$ $I_p = Aq n_i^2 \frac{D_p}{L_p N_D} (e^{V/V_T} - 1)$ $I_n = Aq n_i^2 \frac{D_n}{L_n N_A} (e^{V/V_T} - 1)$	
Saturation current (A)	$I_S = Aq n_i^2 \left(\frac{D_p}{L_p N_D} + \frac{D_n}{L_n N_A} \right)$	
Minority-carrier lifetime (s)	$\tau_p = L_p^2/D_p$ $\tau_n = L_n^2/D_n$	$L_p, L_n = 1 \mu\text{m to } 100 \mu\text{m}$ $\tau_p, \tau_n = 1 \text{ ns to } 10^4 \text{ ns}$
Minority-carrier charge storage (coulomb)	$Q_p = \tau_p I_p$ $Q_n = \tau_n I_n$ $Q = Q_p + Q_n = \tau_T I$	
Diffusion capacitance (F)	$C_d = \left(\frac{\tau_T}{V_T} \right) I$	

mass action law $\Rightarrow n \cdot p = n_i^2$ (for intrinsic)

" " " $\Rightarrow n_{p0} \cdot p_{p0} = n_i^2$ (for doped)

Doped:
 $P_{p0} \rightarrow$ Concentration of holes
 $\rightarrow$ when doped with acceptor
 $\rightarrow$ at equilibrium.
 $n_{p0} \rightarrow$ Concentration of electrons
 $\rightarrow$ when doped with acceptor
 $\rightarrow$ at steady state.

for intrinsic
 * $n_i = n = p$
 * at $T=0 \Rightarrow n = p = 0$
 * There is only THERMAL generation & recombination

Q, Calculate the intrinsic carrier density (n_i)
at: 250k, 300k, 200°C

$$\textcircled{1} \quad n_i^2 = BT^3 e^{-\frac{E_G}{kT}}$$

$$n_i^2 = 5.4 \times 10^{31} \times (250)^3 e^{\left(\frac{-1.12}{8.62 \times 10^{-5} \times 250}\right)}$$

$$n_i^2 = 2.26 \times 10^{16} \Rightarrow n_i = 1.5 \times 10^8 / \text{cm}^3$$

$$\textcircled{2} \quad n_i^2 = 5.4 \times 10^{31} (300)^3 e^{\left(\frac{-1.12}{8.62 \times 10^{-5} \times 300}\right)}$$

$$n_i^2 = 2.26 \times 10^{20} \Rightarrow n_i = 1.5 \times 10^{10} / \text{cm}^3$$

$$\textcircled{3} \quad T = 200 + 273 = 473 \text{ K}$$

$$n_i^2 = 5.4 \times 10^{31} \times (473)^3 e^{\left(\frac{-1.12}{8.62 \times 10^{-5} \times 473}\right)}$$

$$n_i^2 = 6.71 \times 10^{27} \Rightarrow n_i = 8.19 \times 10^{13} / \text{cm}^3$$

3.30 if Si doped with donor $N_D = 10^{17}$, find electron and hole concentration at previous temperature,

$$\textcircled{1} \quad N_D = 10^{17} \Rightarrow \text{electrons} = 10^{17} / \text{cm}^3 = n$$

$$n \cdot p = n_i^2 \Rightarrow \text{holes} = \frac{n_i^2}{n} = \frac{2.26 \times 10^{16}}{10^{17}} = 0.226 / \text{cm}^3$$

$$\textcircled{2} \quad n = N_D = 10^{17} / \text{cm}^3$$

$$p = \frac{n_i^2}{n} = \frac{2.26 \times 10^{20}}{10^{17}} = 2.26 \times 10^3 / \text{cm}^3$$

$$\textcircled{3} \quad n = N_D = 10^{17} / \text{cm}^3$$

$$\frac{n_i^2}{n} = p = \frac{6.71 \times 10^{27}}{10^{17}} = 6.71 \times 10^{10} / \text{cm}^3$$

Ex 3.31) find the resistivity of

(a) intrinsic silicon (b) p-type with $N_A = 10^{16}/\text{cm}^3$

use $n_i = 1.5 \times 10^{10}/\text{cm}^3$, $\mu_n = 1350 \text{ cm}^2/\text{V}$, $\mu_p = 480 \text{ cm}^2/\text{V}$
for intrinsic

use for doped $\mu_n = 1110 \text{ cm}^2/\text{V}$, $\mu_p = 400 \text{ cm}^2/\text{V}$

(*) find the resistance if $L = 3 \mu\text{m}$, width = $3 \mu\text{m}$, thick = $1 \mu\text{m}$

$$\textcircled{1} \rho = \frac{1}{q(P\mu_p + n\mu_n)} \Rightarrow n = 1.5 \times 10^{10} = p \text{ for intrinsic}$$

$$\rho = \frac{1}{1.6 \times 10^{-19} [1.5 \times 10^{10} \times 1350 + 1.5 \times 10^{10} \times 480]} = 2.28 \times 10^5 \Omega \cdot \text{cm}$$

المقاومة لكل سم

$$R = \rho \frac{L}{A} = 2.28 \times 10^5 \times \frac{3 \mu\text{m}}{3 \mu\text{m} \times 1 \mu\text{m}} = \frac{2.28 \times 10^5}{1 \times 10^{-4} \text{ cm}} = 2.28 \times 10^9 \Omega$$

$$\textcircled{2} \rho = \frac{1}{q(P\mu_p + n\mu_n)} ; P = N_A = 10^{16}/\text{cm}^3$$

$$n_i = 1.5 \times 10^{10} \Rightarrow n = \frac{n_i^2}{P} = \frac{(1.5 \times 10^{10})^2}{10^{16}} = 225 \times 10^3 / \text{cm}^3$$

نصف الناقل

$$\rho = \frac{1}{1.6 \times 10^{-19} (10^{16} \times 400 + 225 \times 10^3 \times 1110)} = 1.56 \Omega \cdot \text{cm}$$

$$R = \rho \frac{L}{A} = 1.56 \times \frac{3 \mu\text{m}}{3 \mu\text{m} \times 1 \mu\text{m}} = 1.56 \times \frac{1}{10^{-4} \text{ cm}} = 1.56 \times 10^4 \Omega$$

if doping is n-type $N_D = 10^{16}$

$$n = N_D = 10^{16} \Rightarrow p = \frac{(1.5 \times 10^{10})^2}{10^{16}} = 225 \times 10^3 / \text{cm}^3$$

$$\rho = \frac{1}{q(n\mu_n + p\mu_p)} = \frac{1}{1.6 \times 10^{-19} (10^{16} \times 1110 + 225 \times 10^3 \times 400)} = 0.583 \Omega \cdot \text{cm}$$

Cont

Cont / Some of problem 3.112

* if temperature was increased to 473 K

what is ρ for previous case (2). (n_i depends on T)

Ans: $N_A = 10^{16} / \text{cm} = p$ * لا يعتمد على الحرارة

$$n_i^2 = 6.71 \times 10^{27} \Rightarrow n = \frac{n_i^2}{p} = \frac{6.71 \times 10^{27}}{1 \times 10^{16}} = 6.71 \times 10^{11} / \text{cm}^3$$

* يعتمد على الحرارة.

473 - see problem (1)

$$\rho = \frac{1}{q(n n_p + p p_p)} = \frac{1}{1.6 \times 10^{-14} (6.71 \times 10^{11} \times 1110 + 10^{16} \times 400)} = 1.56 \text{ } \Omega \cdot \text{cm}$$

السلسلة المخطئة لحل السؤال

(1) ادرس تأثير درجة الحرارة بـ n_i أولاً

(2) كتب N_A, N_D, n_i معرفة

(3) كتب p مع أخذ المخطئين N_A, N_D لأنها قد تتغير في المخطئين.

إذا كان السؤال بأكثر من مقترعة وبغير بعض المخطئين

ابداً من الخطوة (1) حتى لا يخطئ بالحسابات.